



Vrije Universiteit Brussel



B-PHOT
BRUSSELS
PHOTONICS
TEAM

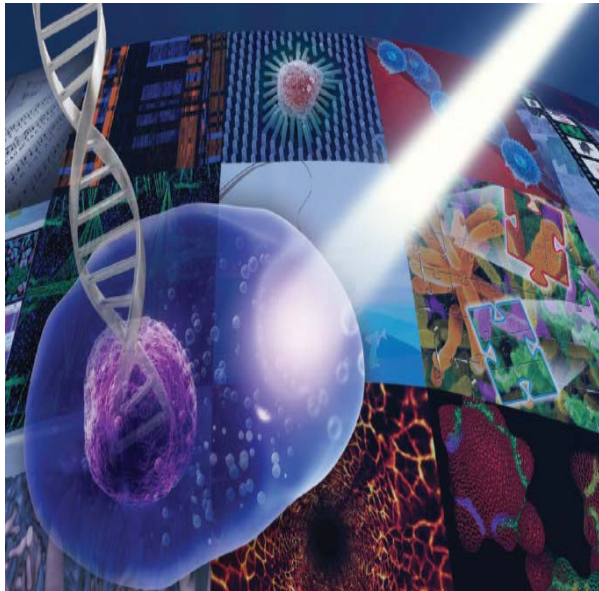
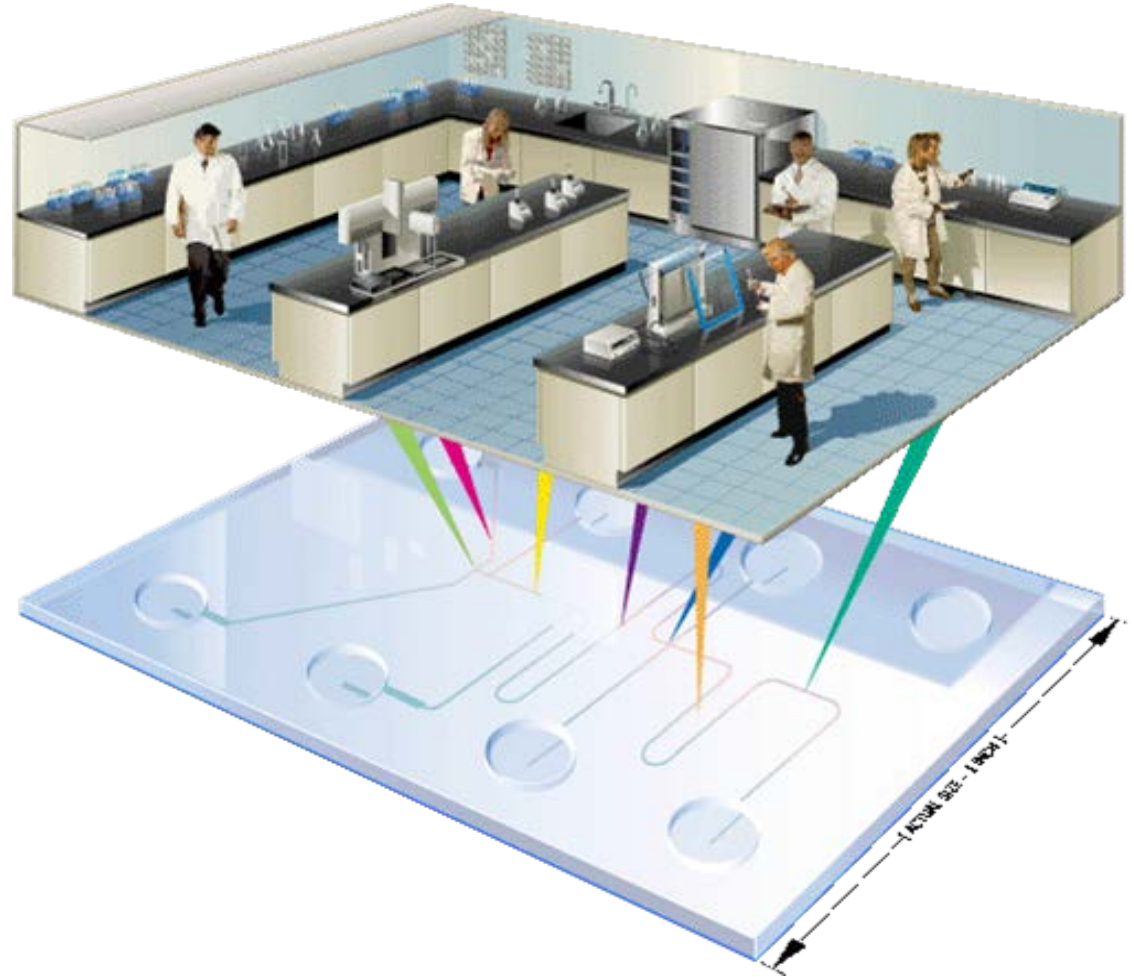
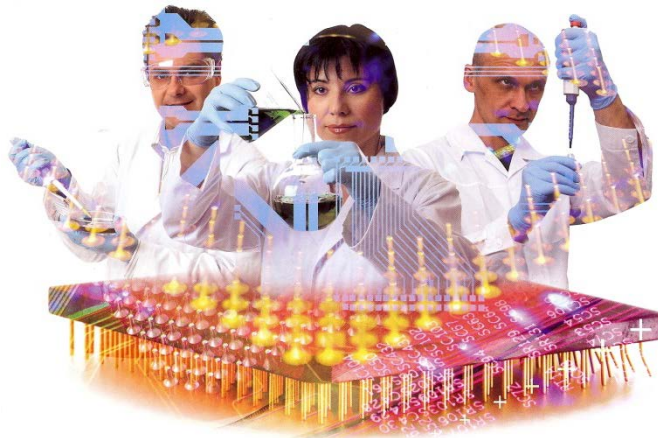
Photonics-enhanced Polymer Labs-on-Chips: from high-tech prototyping platform to applications

Jürgen Van Erps

Biosensors & Bioelectronics 2015
Hilton Atlanta Airport (USA)



Lab-on-a-chip



Lab-on-a-chip for point-of-care diagnostics



Multifunctional micro-systems

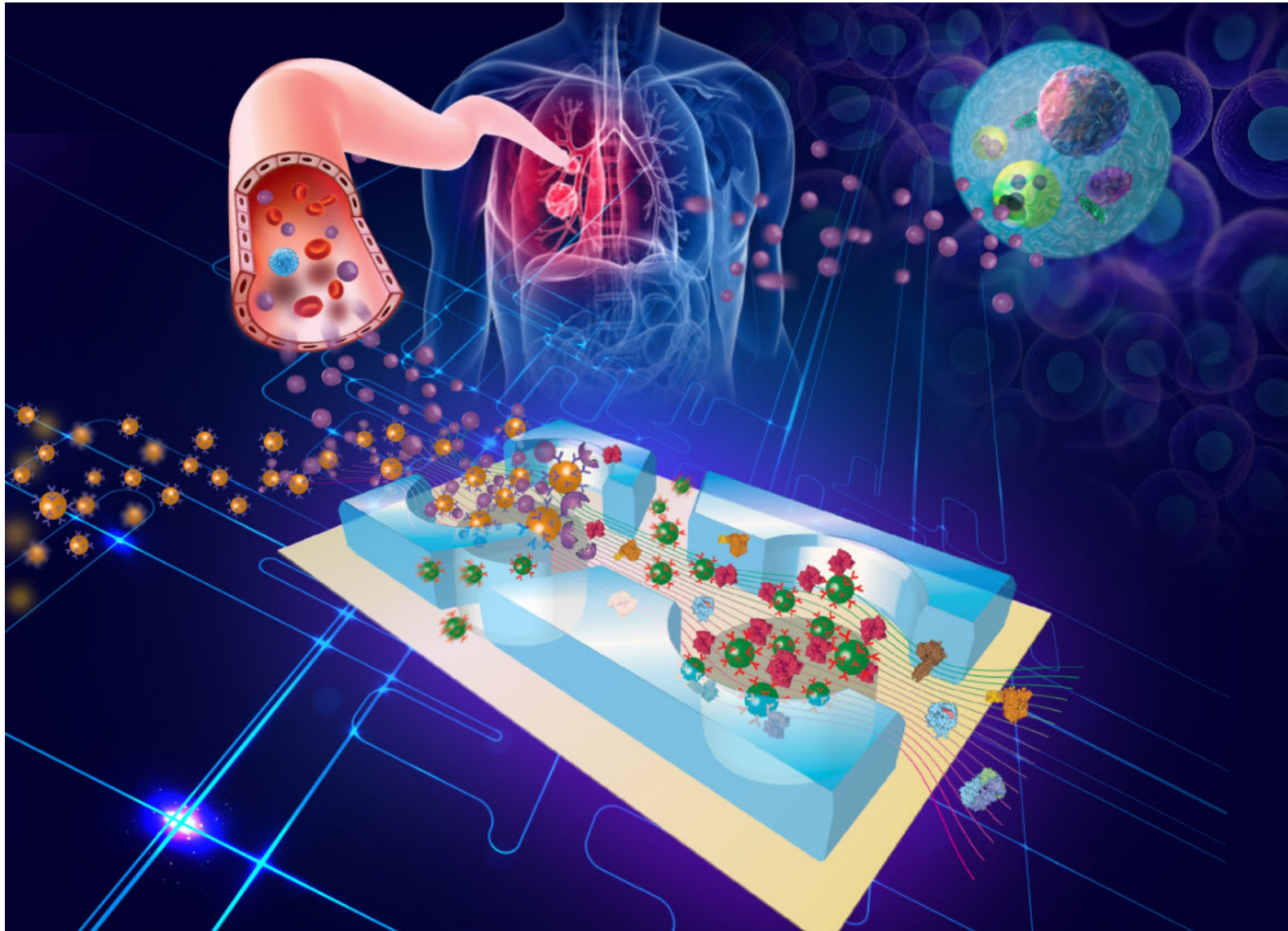


Health



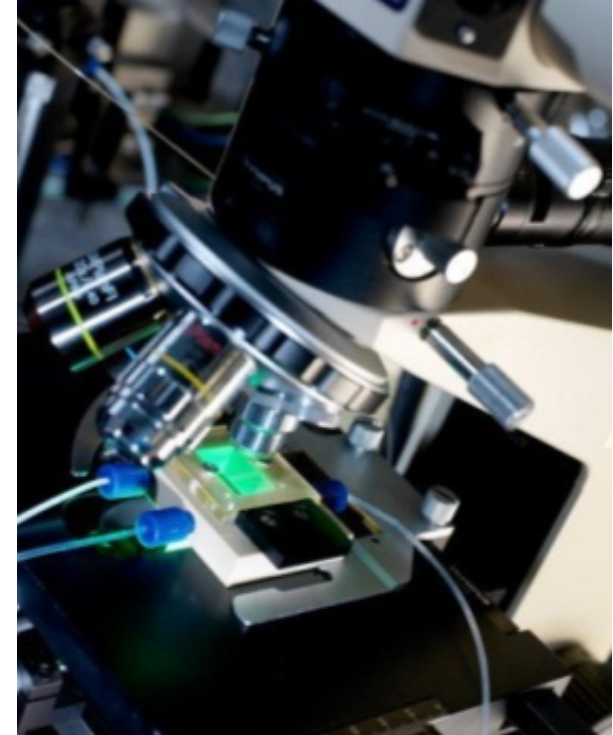
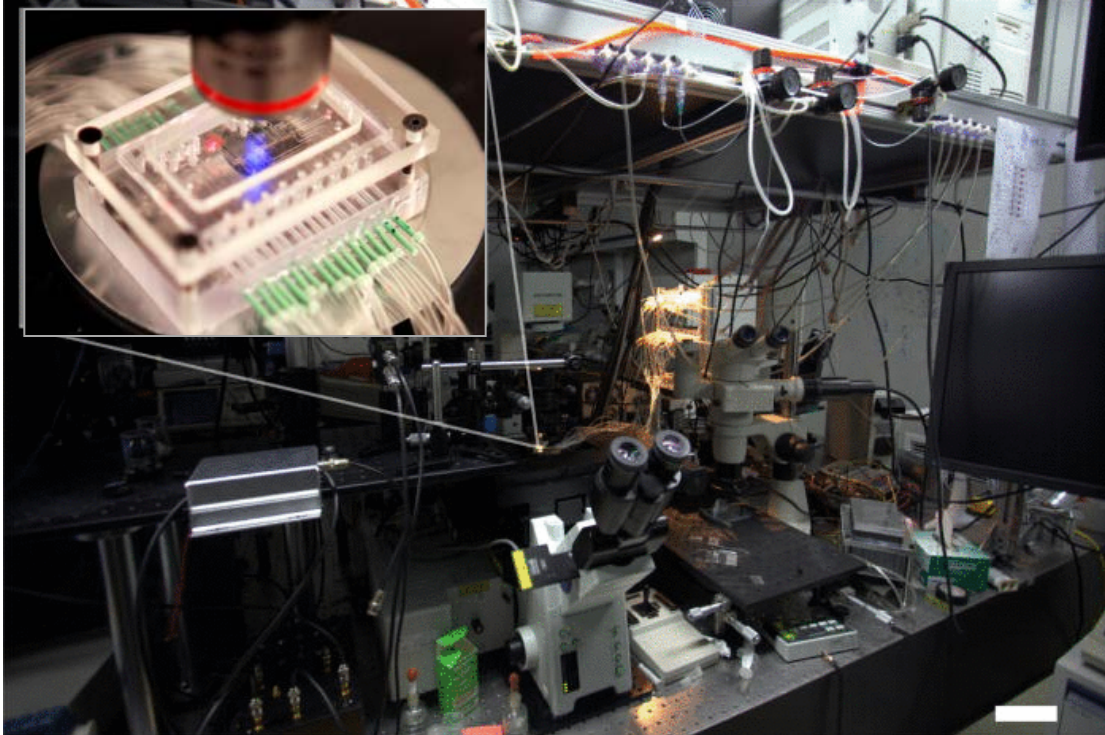
Water and food

Human-on-a-chip



Lab-on-a-chip Challenges

- Limited to laboratory prototypes without widespread use in clinical or high-throughput applications
 - Detection is done using bulky and expensive instrumentation: “chip-in-a-lab” rather than a lab-on-a-chip



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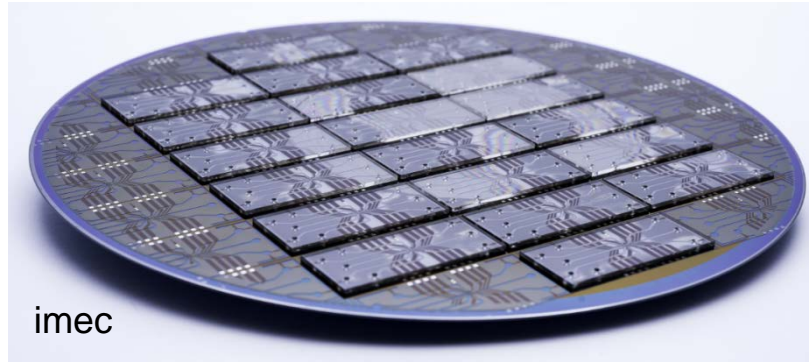


Need for miniaturized and integrated detection



- Limited to laboratory prototypes without widespread use in clinical or high-throughput applications
 - A wide variety of approaches and competing material platforms

Si / SiN



Glass

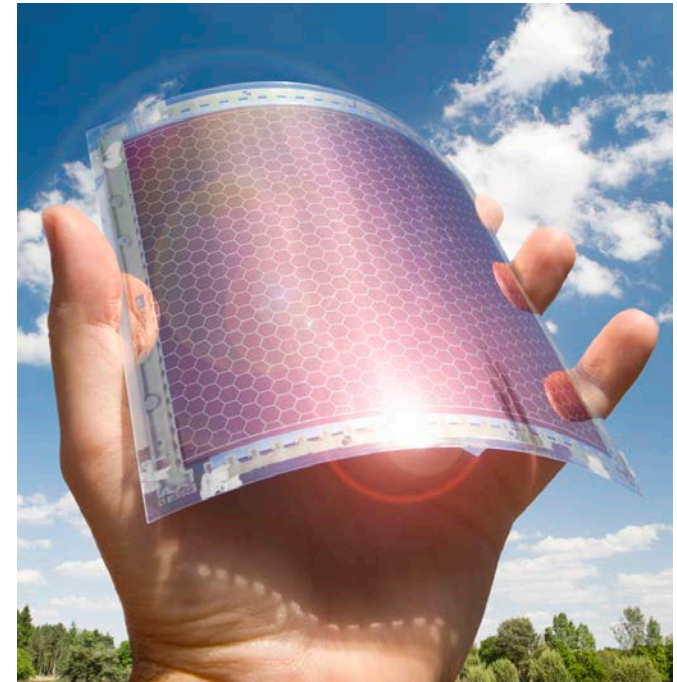


Polymers



The future could be plastic...

- Flexible organic photovoltaics as a low-cost alternative to silicon photovoltaic cells

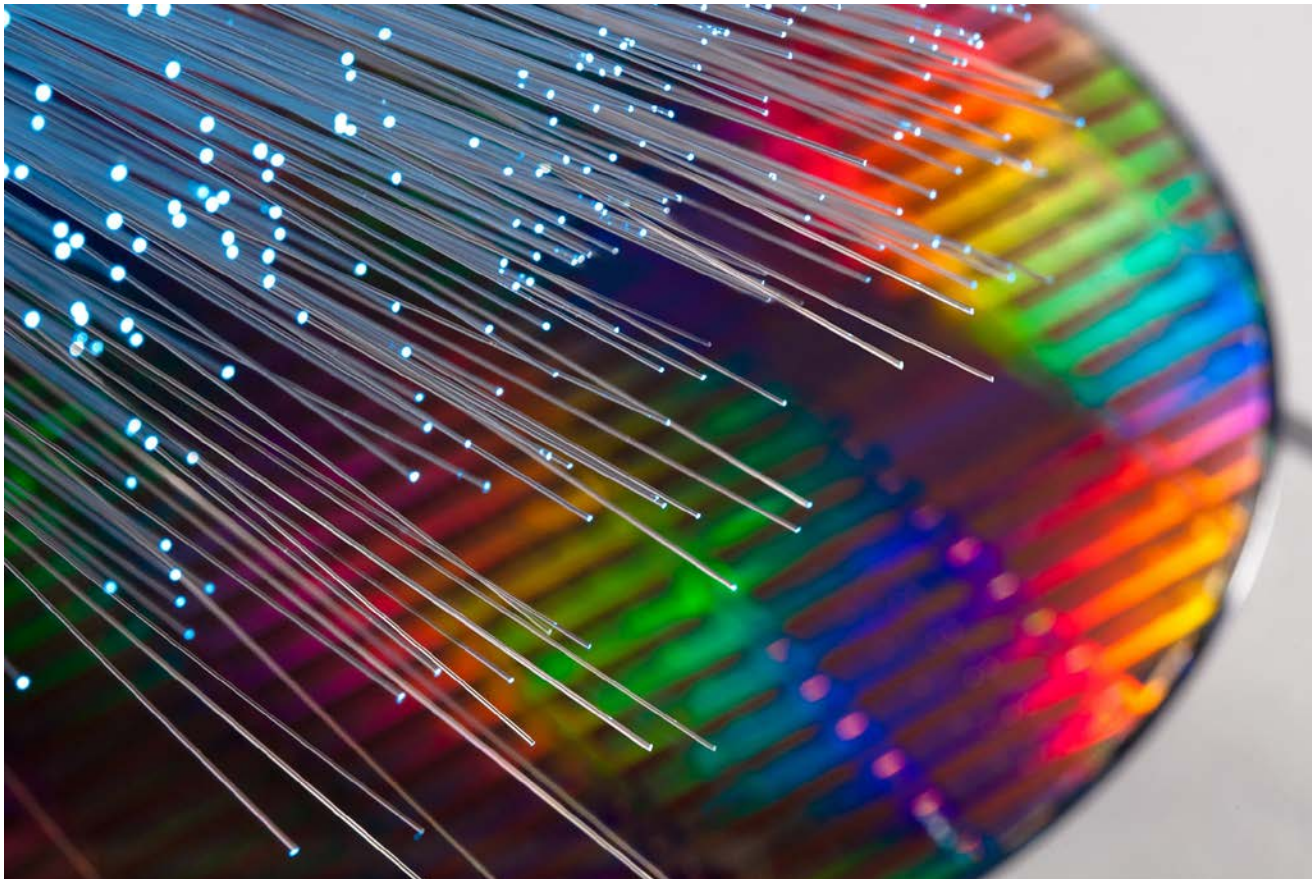


- From rigid LCD displays to flexible OLED displays



The future could be plastic...

- From glass fiber for long-haul optical telecom to polymer optical fiber for short-distance interconnects



The future could be plastic...

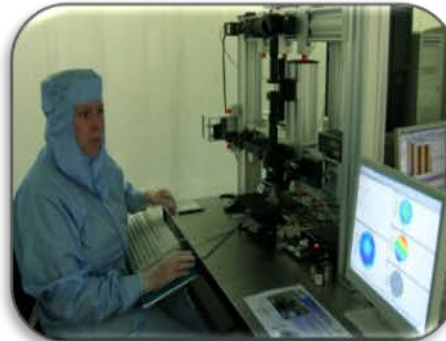
- Towards ubiquitous polymer labs-on-chips?
 - Low-cost wafer-scale mass manufacturing
 - Wide range of material properties (e.g. T_g)
 - Biocompatible
 - Biodegradable
 - Disposable
 - Surface functionalization



B-PHOT's micro-optics technology supply chain



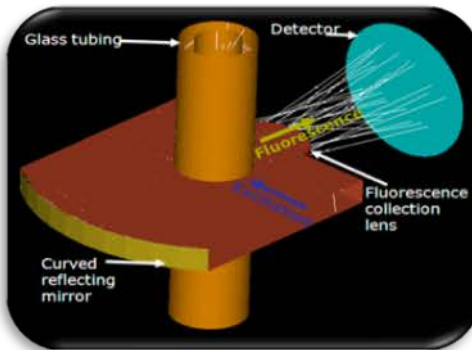
Mastering and Prototyping Technologies



Optical Measurement and Characterization



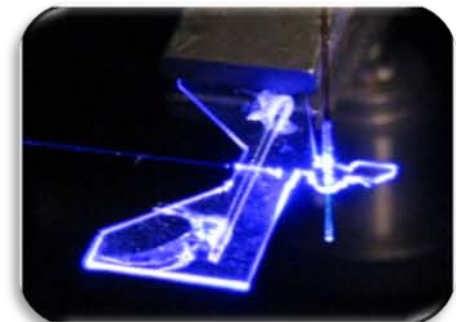
Low-Cost Low-Volume Replication



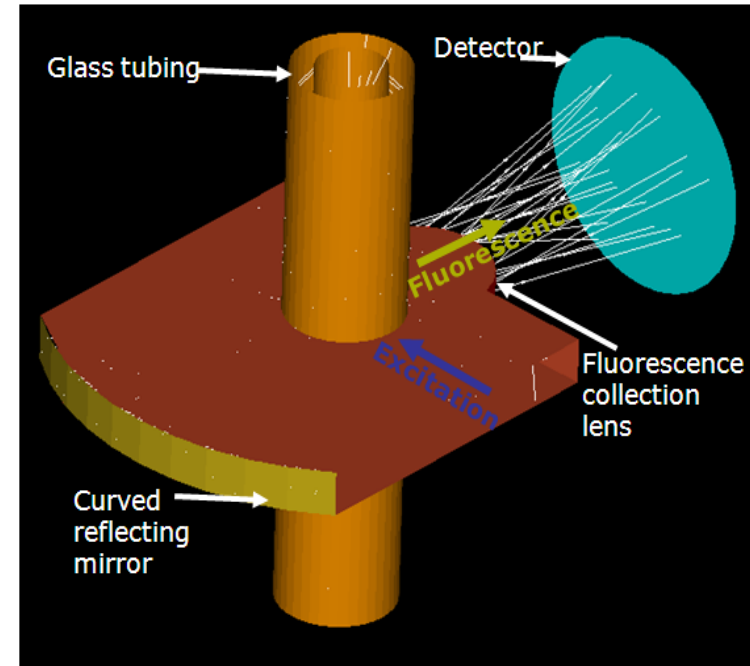
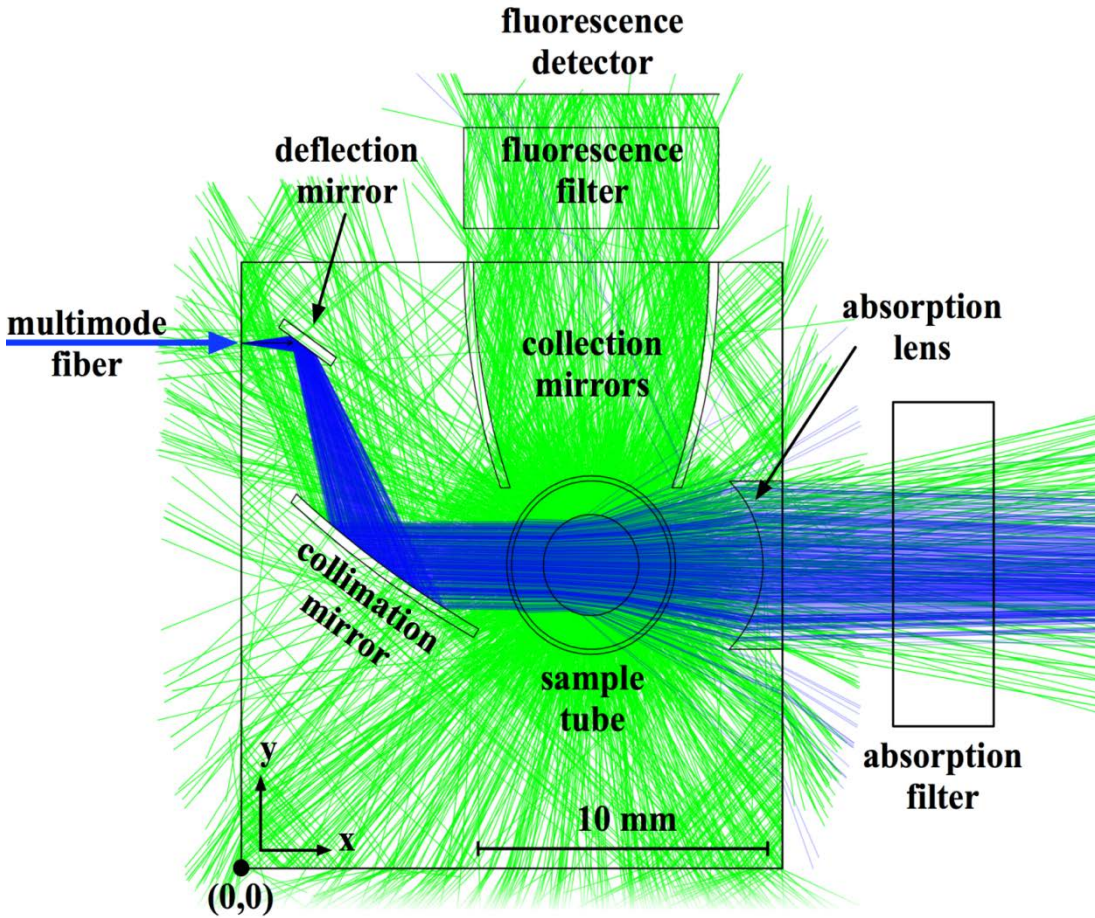
Optical Modelling



Advanced Materials



Demonstrators and Prototypes



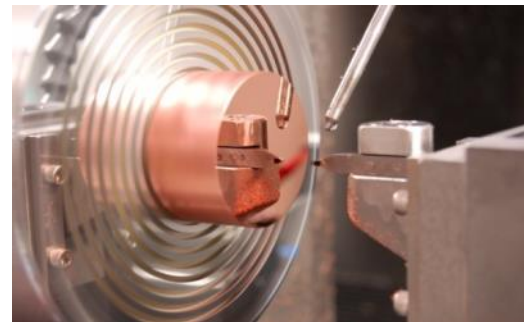
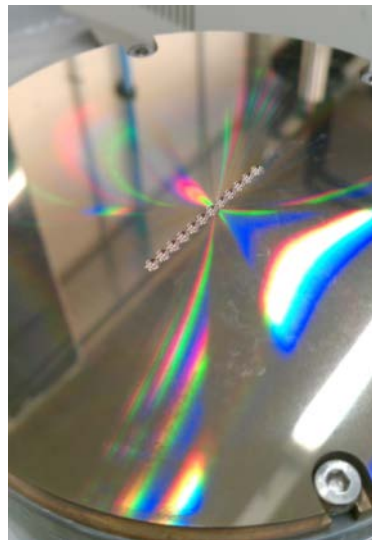
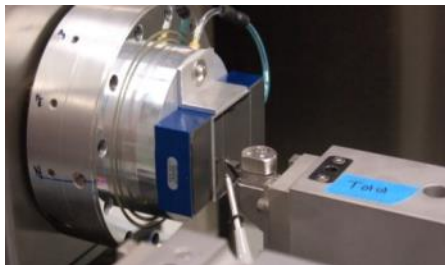
Ray-tracing of polymer labs-on-chips



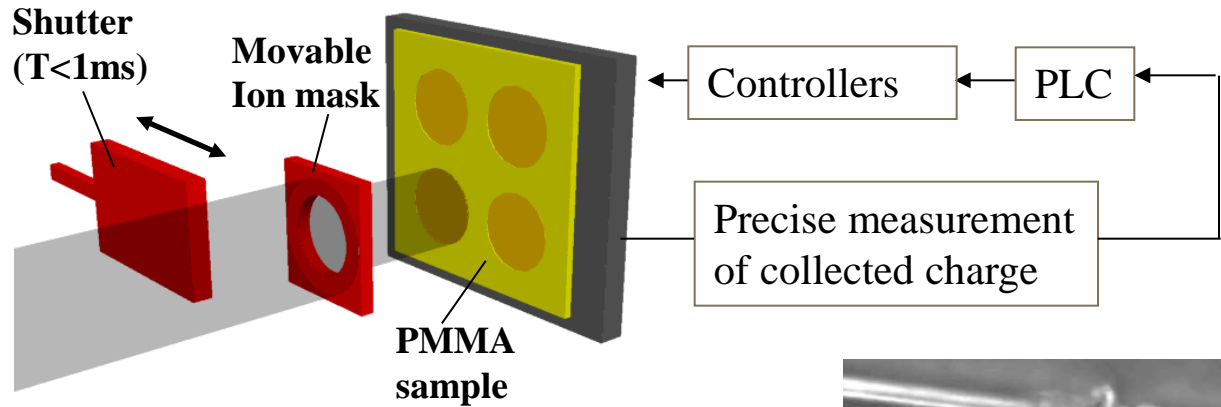
We operate an advanced Polymer Prototyping Line



- Ultraprecision machining: <140 nm PV and $R_a < 5$ nm
- Materials
 - Non-ferrous metals for mould formation
 - Polymers for direct prototyping
- Applications
 - Freeform one step optics
 - Micro-optics on non-flat substrates in diverse materials
 - Mould fabrication



CGR-560 cyclotron



**DPW
vacuum
chamber**



Selective proton irradiation of PMMA

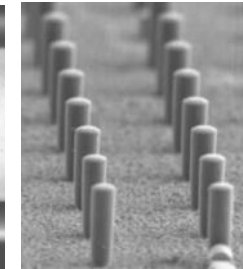
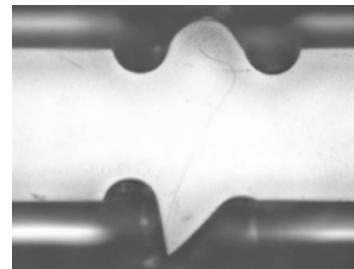
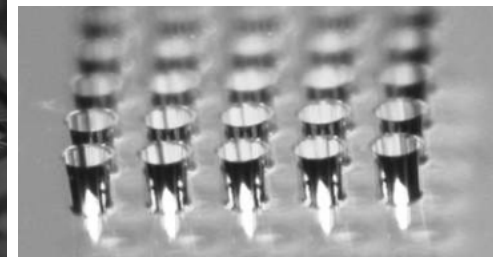
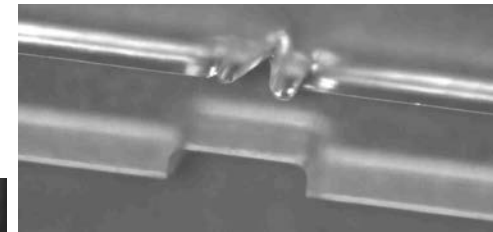
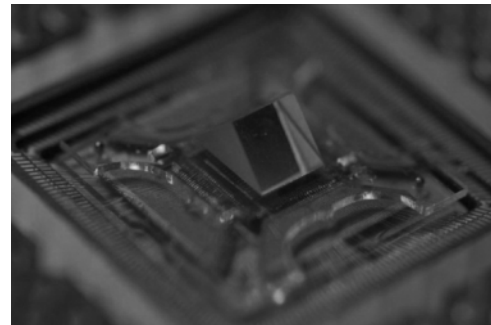
Local energy transfer of 12MeV proton beams results in highly defined degraded points and contours

Proton beam size = 20 μ m – 300 μ m

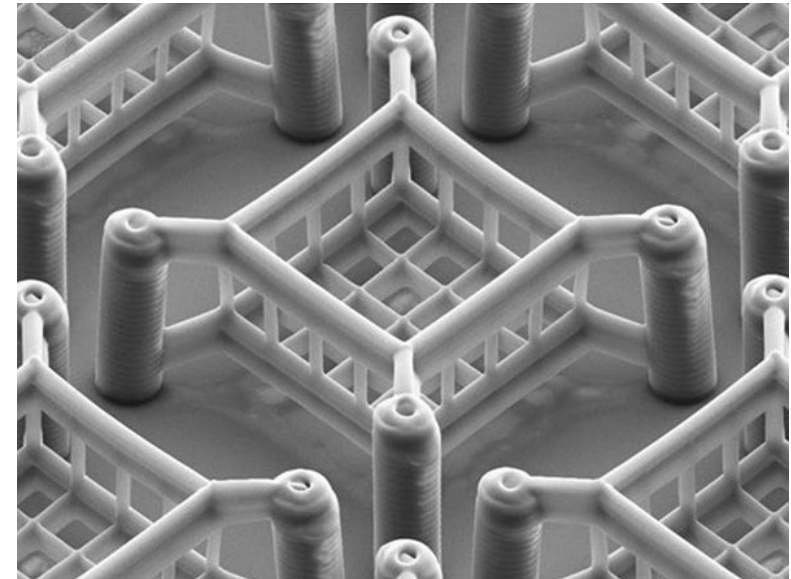
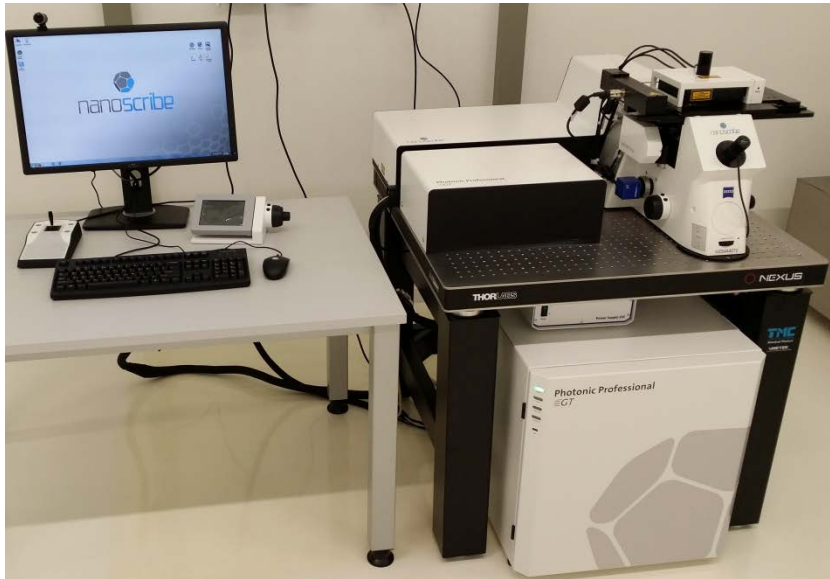
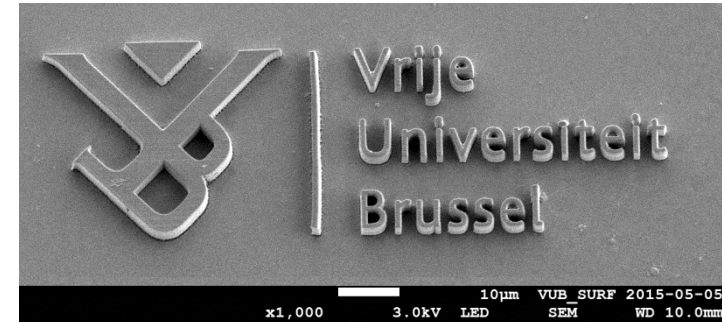
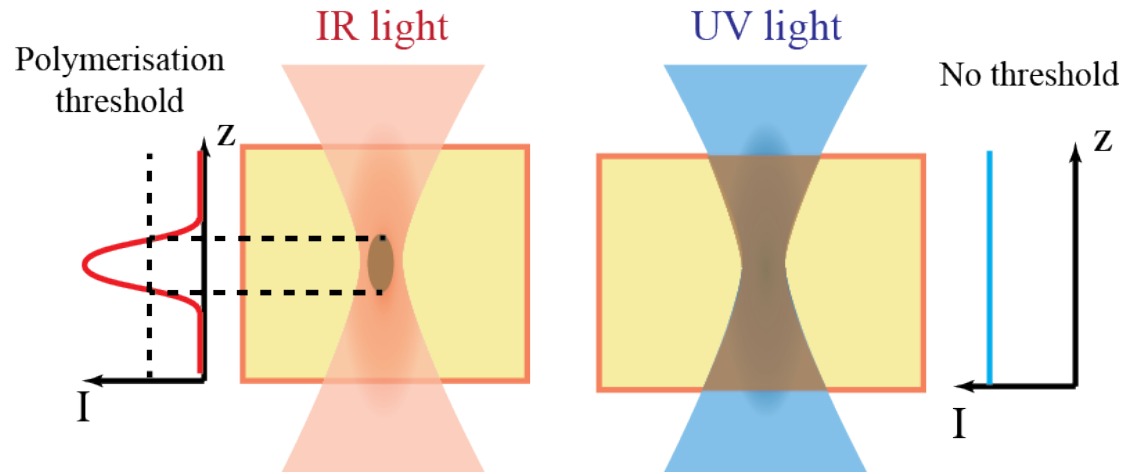
Translation precision of PMMA plates = 50nm

Translation range = 50mm x 50mm

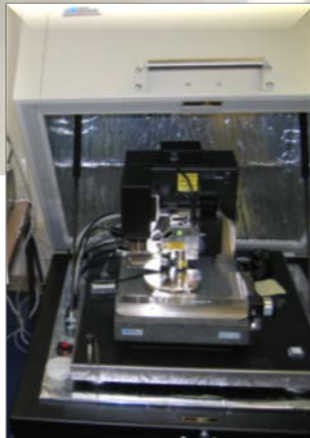
Process optimized up to 2mm thick PMMA plates



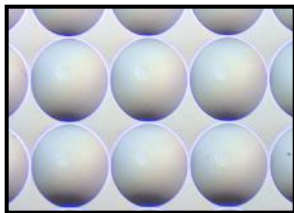
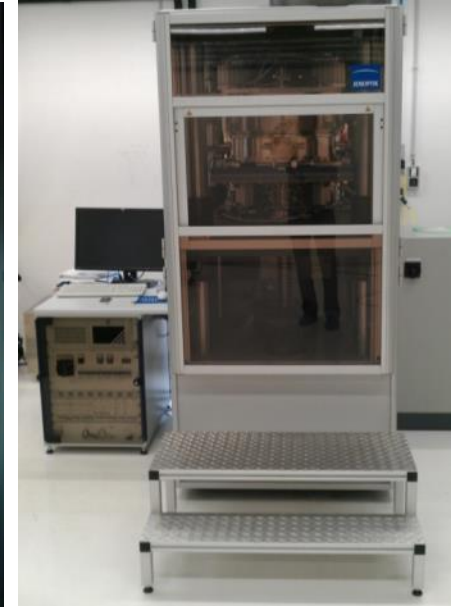
We enter the next paradigm shift using 3D-laser lithography with biopolymers



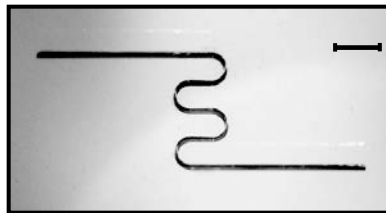
ISO class 7 cleanroom facility



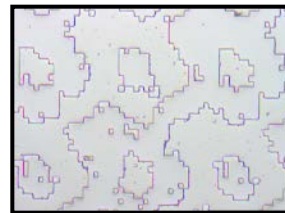
- 300 mm wafer capacity
- Double-sided embossing (Mould alignment $<2\ \mu\text{m}$)
- Typical cycle times: 5 minutes
- Maximum temp.: $(350\pm 2)^{\circ}\text{C}$
- Maximum force: 450 kN
- Low- temperature UV embossing (nano-imprinting) possible



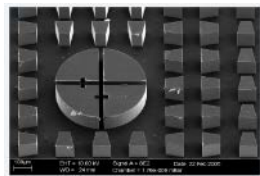
Micro-lenses



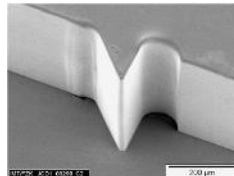
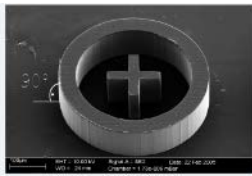
Microfluidic channels



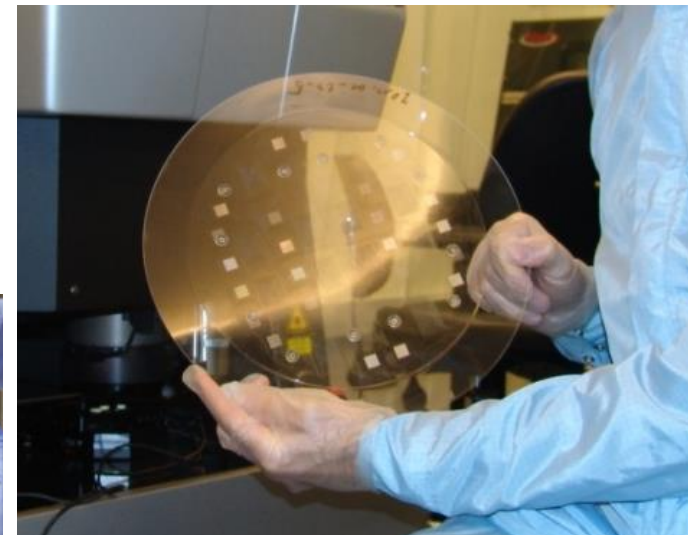
Diffractive optics



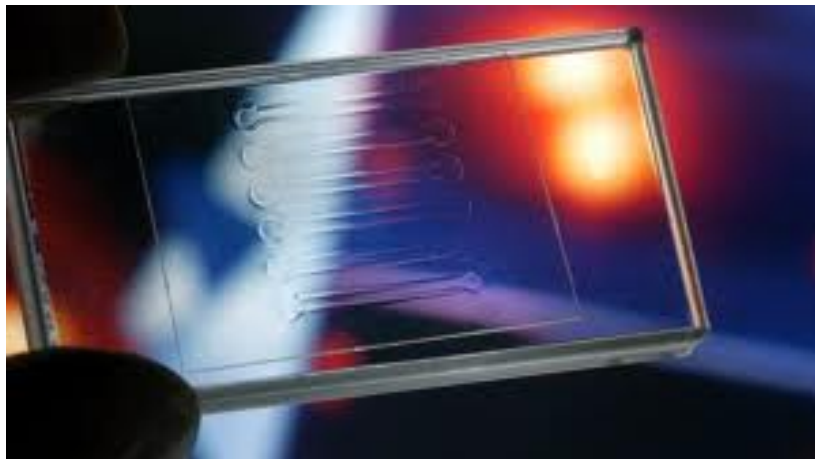
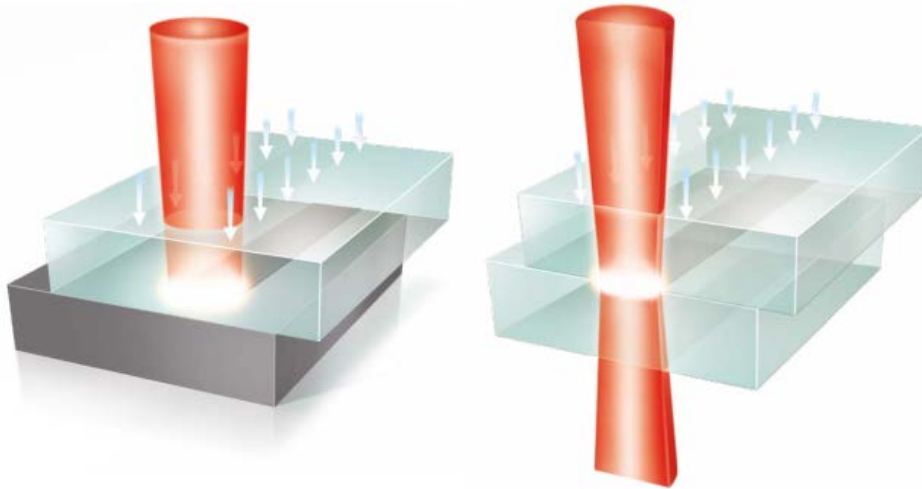
Pillars / Alignment marks



Micromirrors

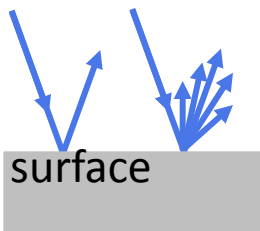


We apply clear-to-clear laser welding of 300mm wafers to seal the microfluidic channels

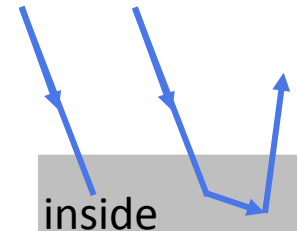


UV-VIS-NIR (250-1600nm)

specular/diffuse reflection

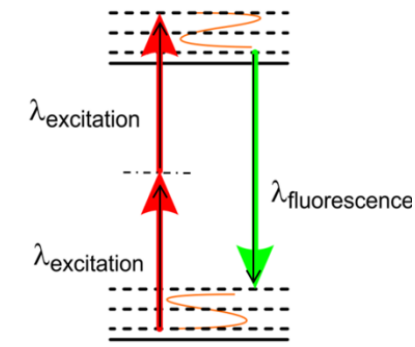
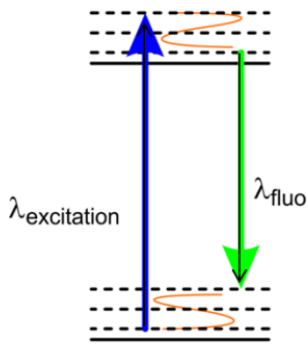
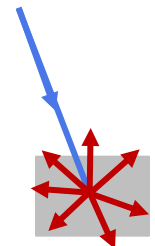


polarization

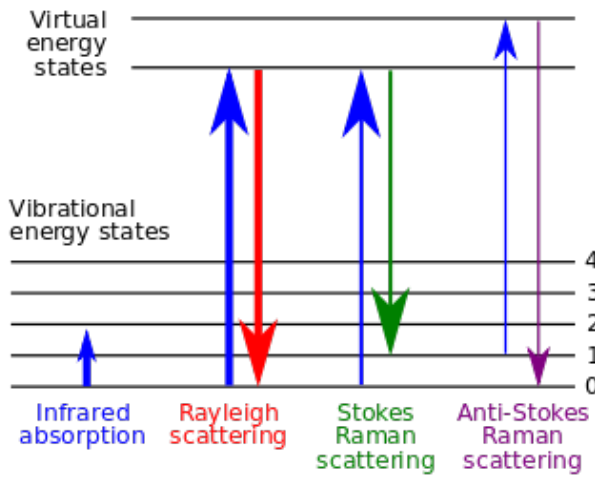


selective & internal vibrational absorption scattering

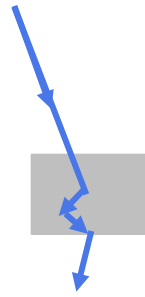
fluorescence (OPIF & TPIF)



Raman scattering

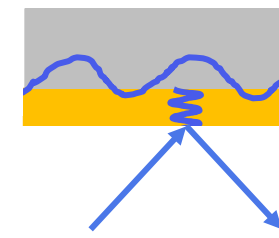


refraction



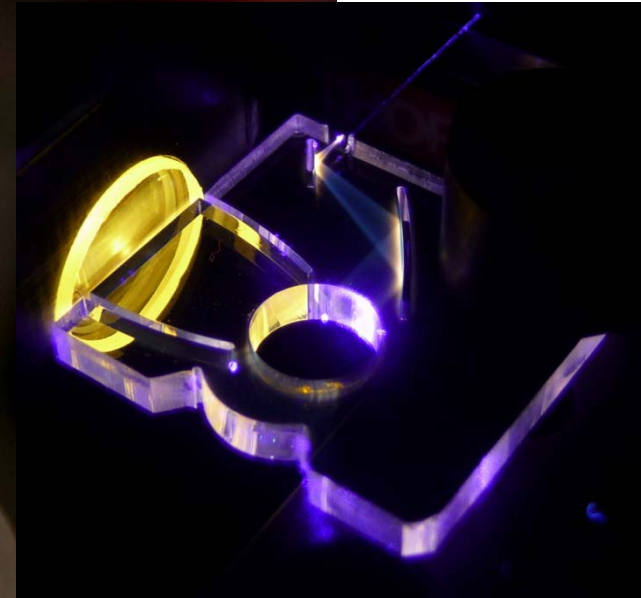
Transmission/Absorption

Surface Plasmon Resonance (SPR)

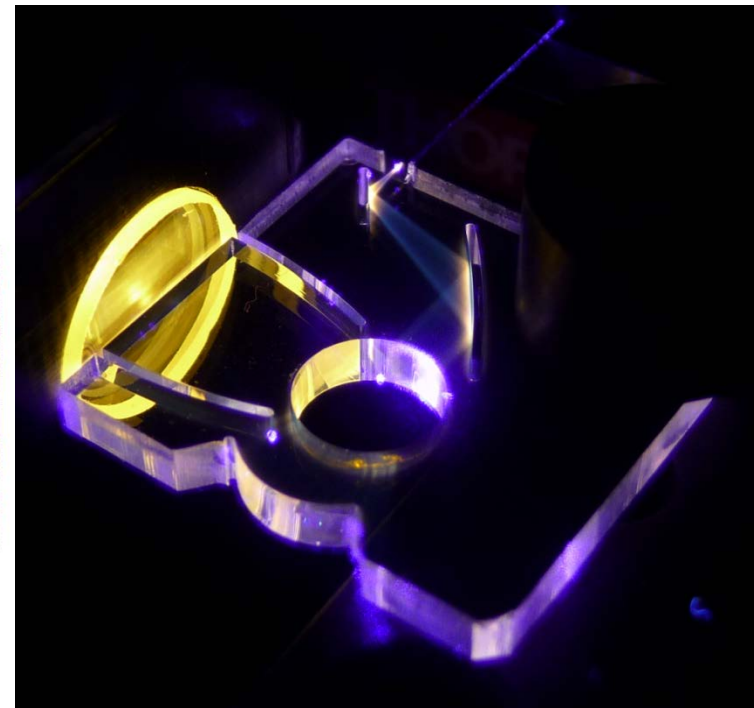
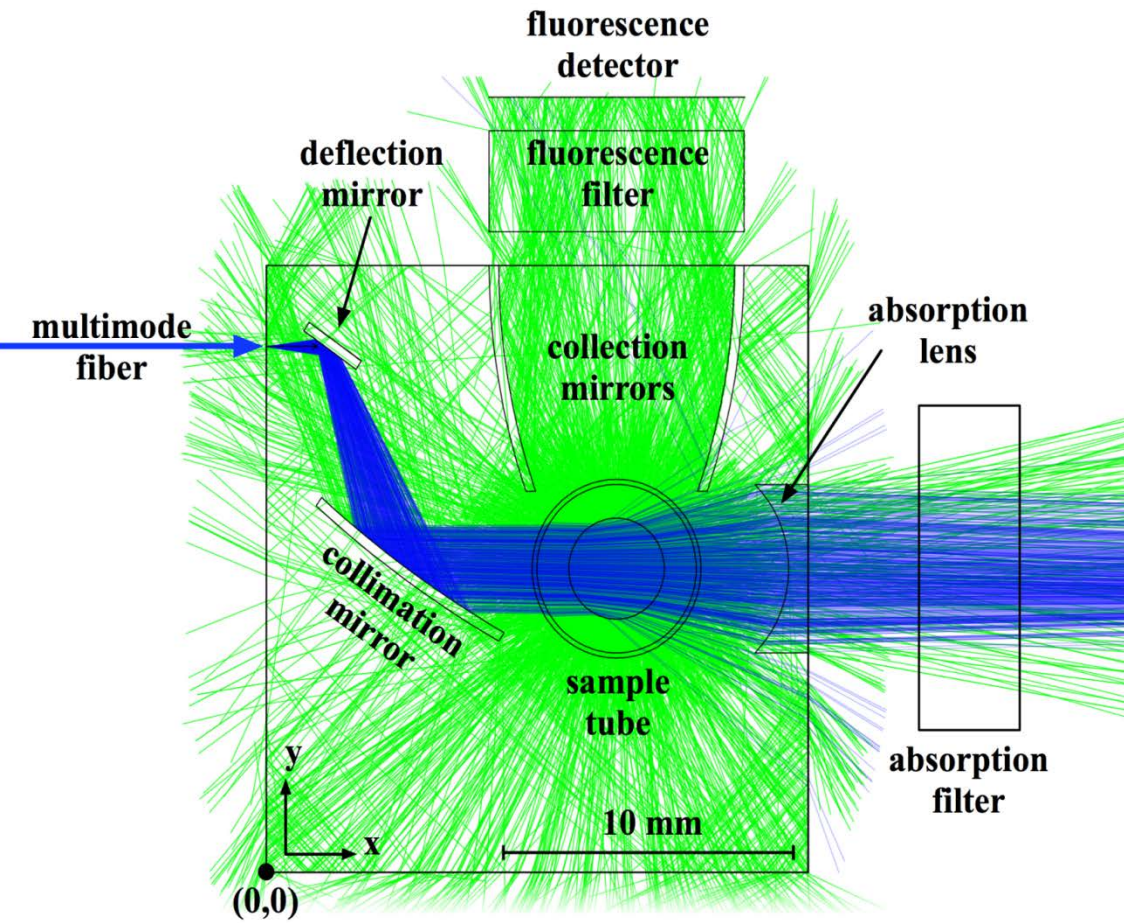


- **A combined absorbance and fluorescence detection module for lubricant oil monitoring**

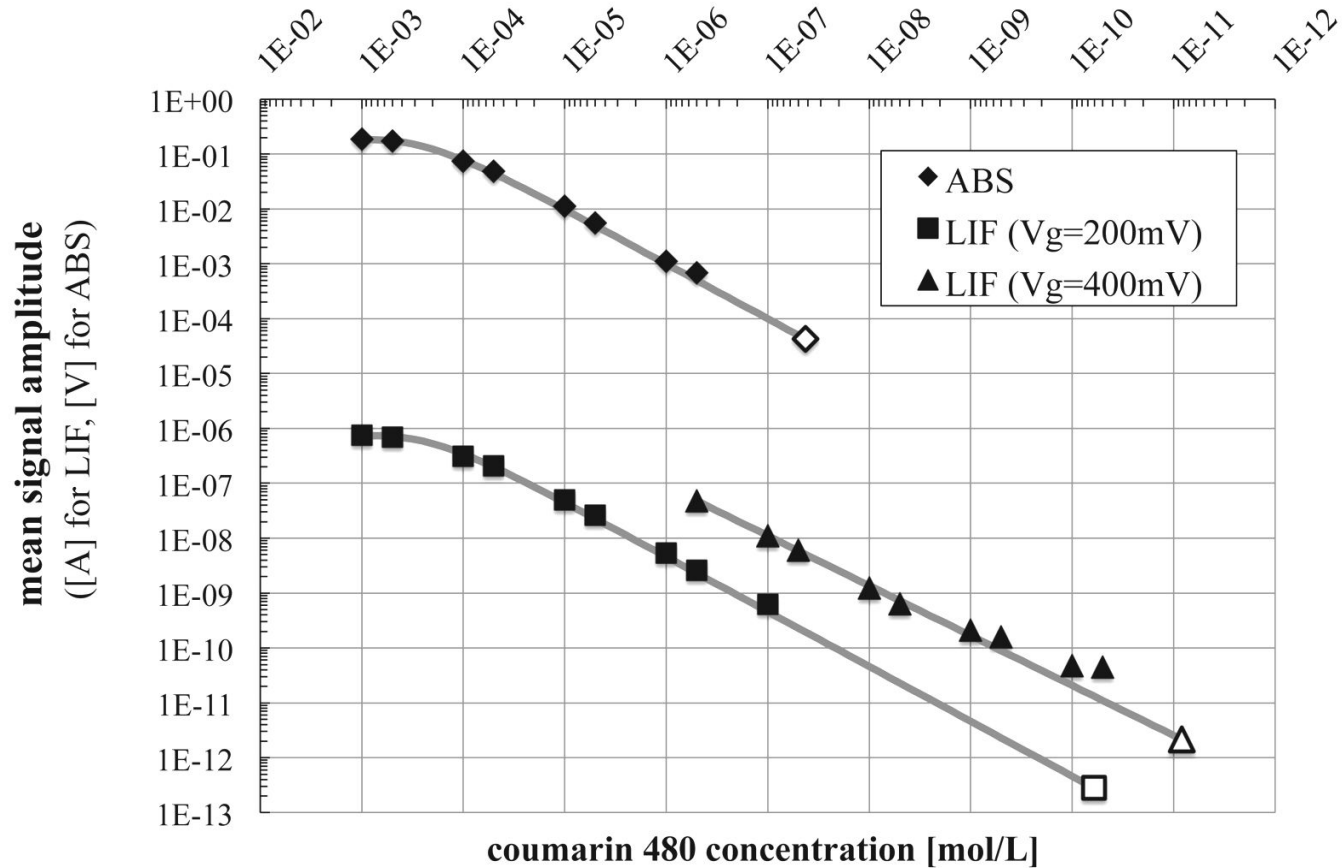
- **A free-form optofluidic chip for confocal Raman spectroscopy measurements**



Combined absorbance and fluorescence detection module for lubricant oil monitoring



- Calibration curves to define LoC performance

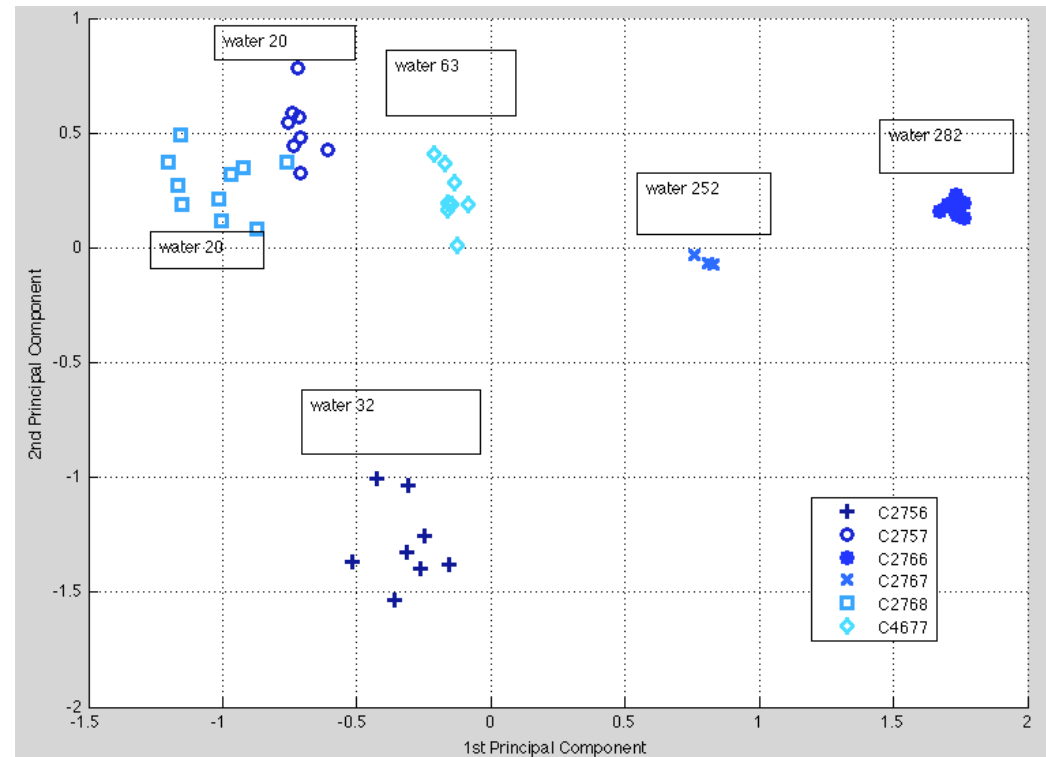
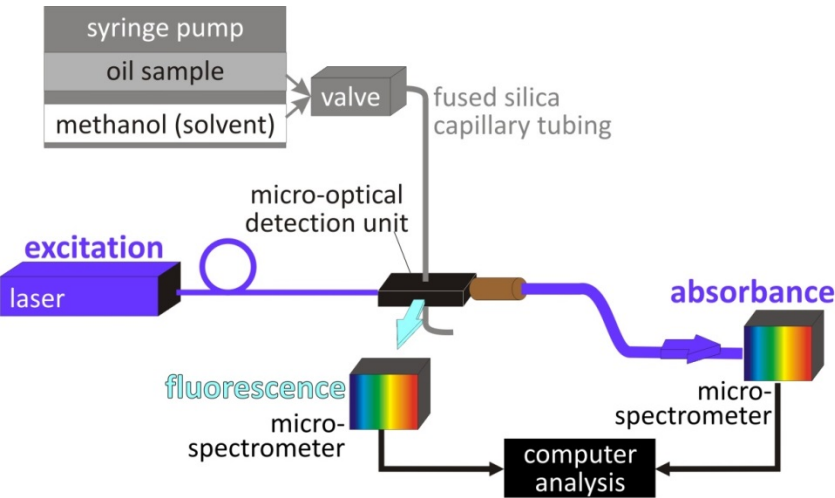


ABS: Experimental LOD = 500nM

LIF: Experimental LOD = 50pM

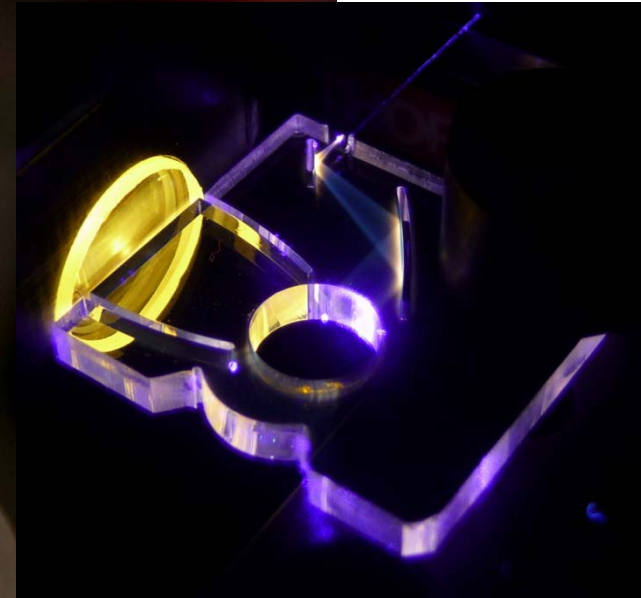
Limit Of Detection LOD = smallest concentration that can be measured with an SNR ≥ 3.3

- Application of the LoC for lubricant oil monitoring

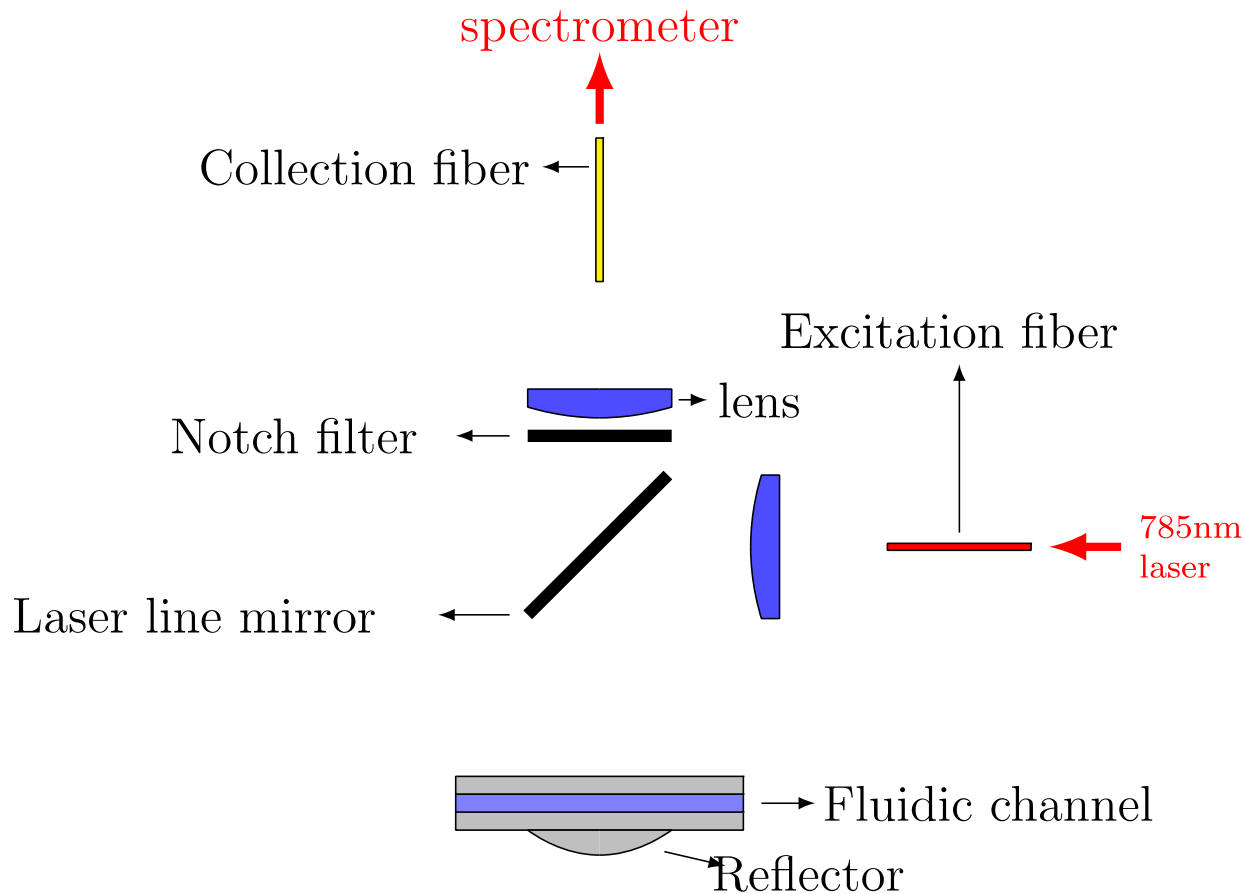


- **A combined absorbance and fluorescence detection module for lubricant oil monitoring**

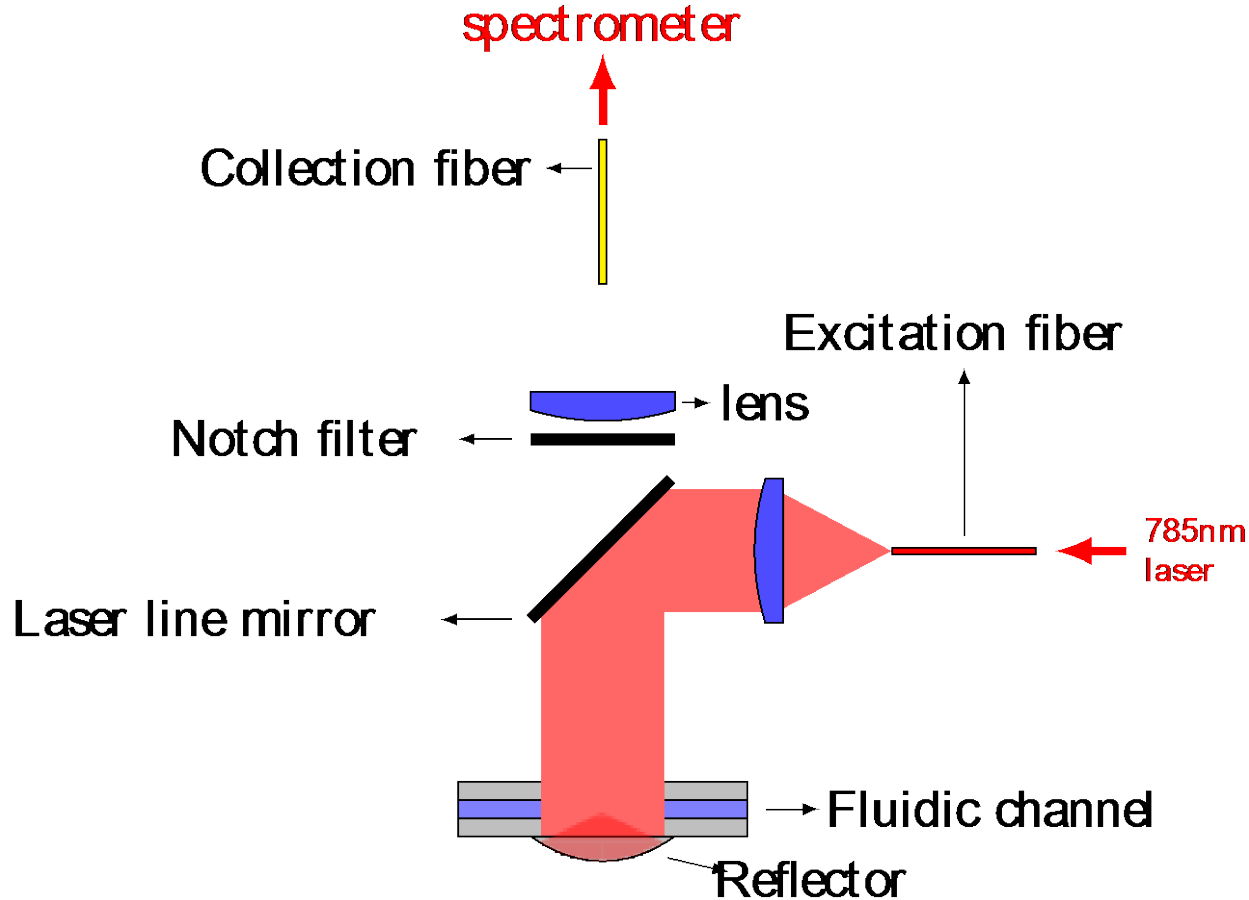
- **A free-form optofluidic chip for confocal Raman spectroscopy measurements**



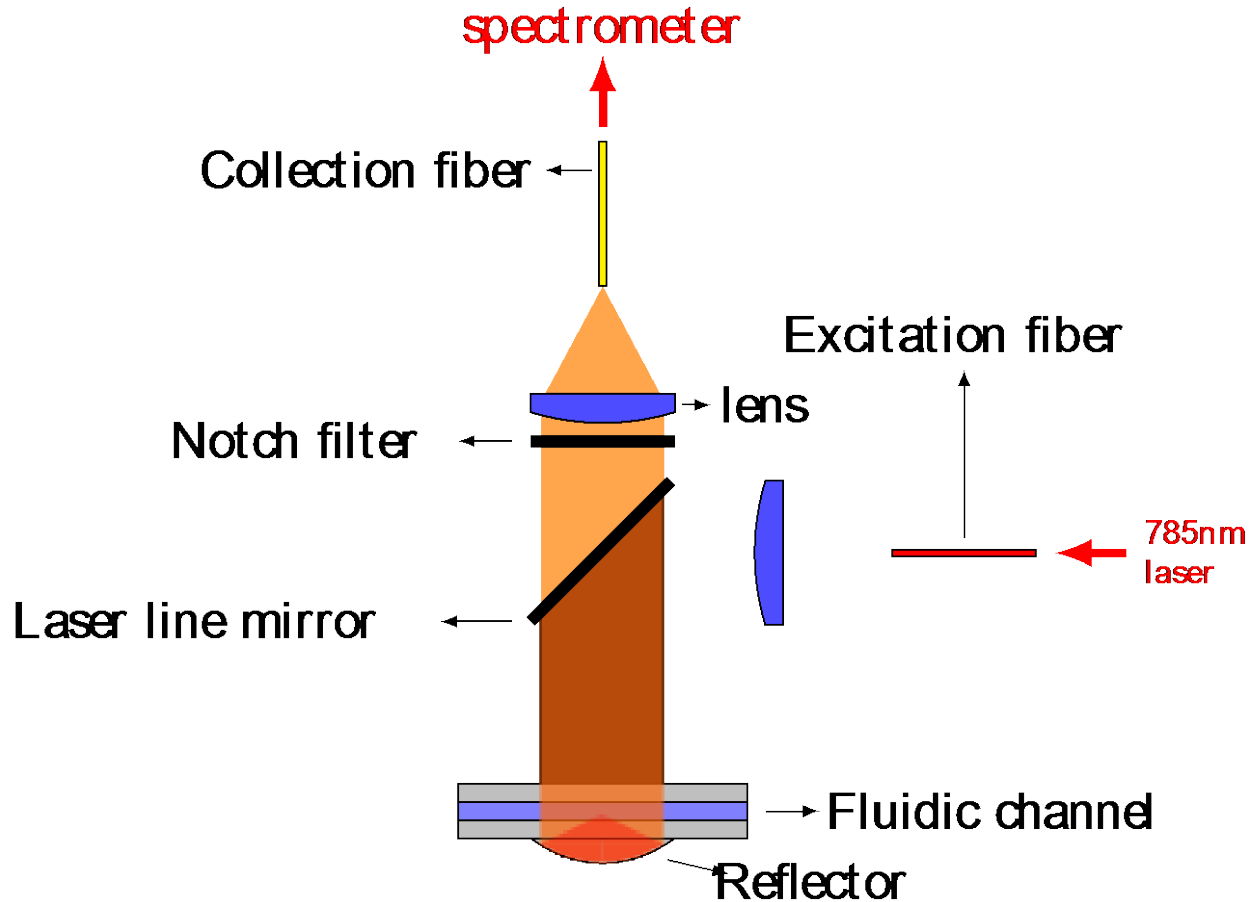
Confocal Raman-on-chip measurement device



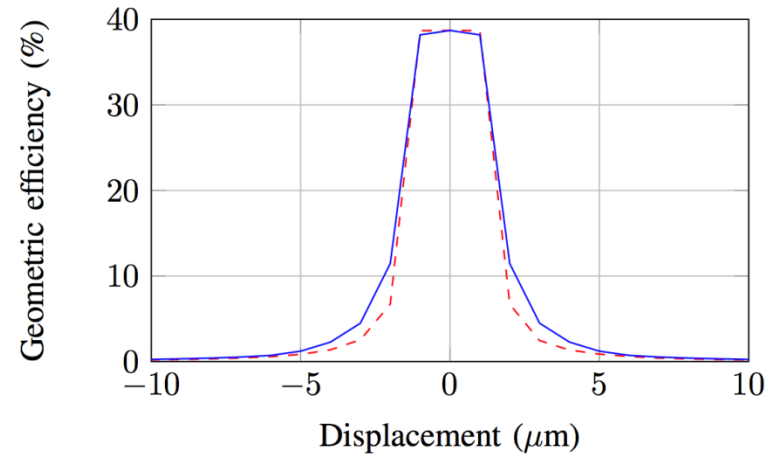
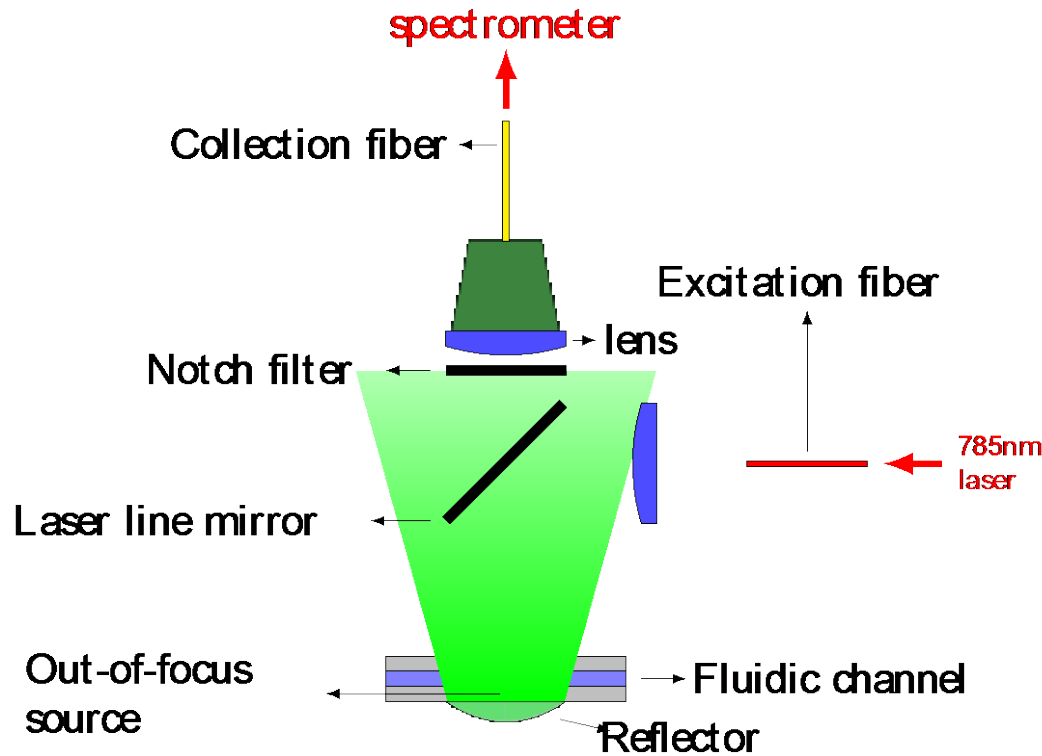
- Excitation path:



- Collection path:

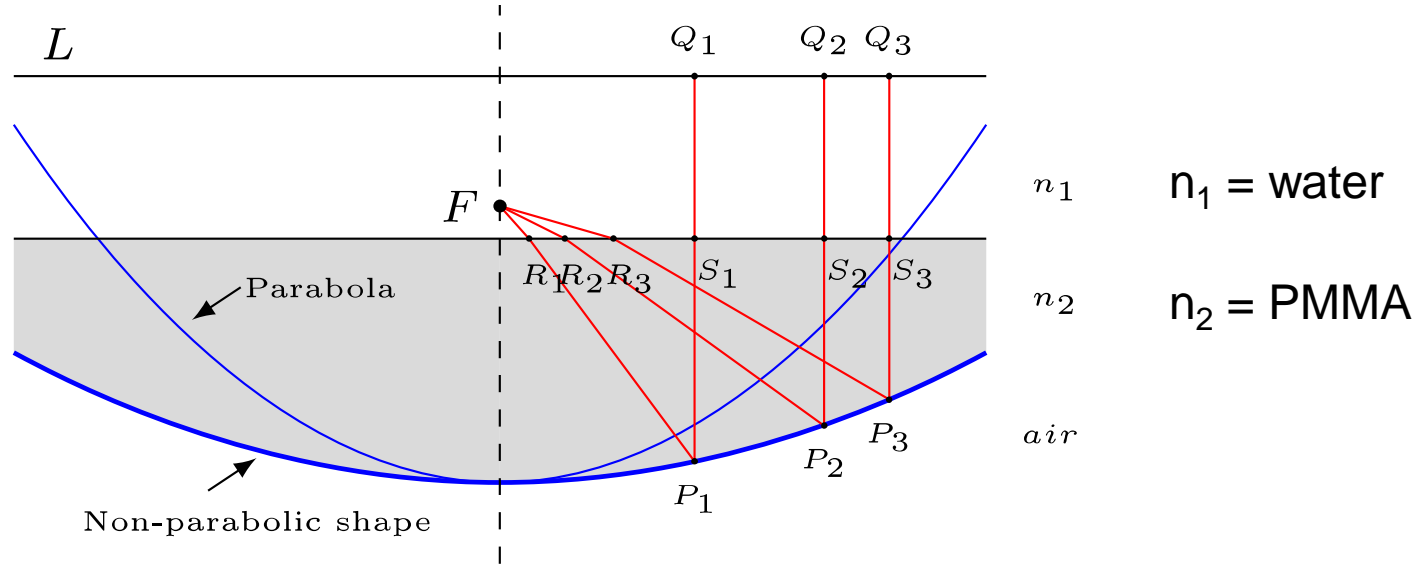


- Minimize background by using the collection fiber as a pinhole:



- using the principle of confocal microscopy
- background light is not focused into the collection fiber

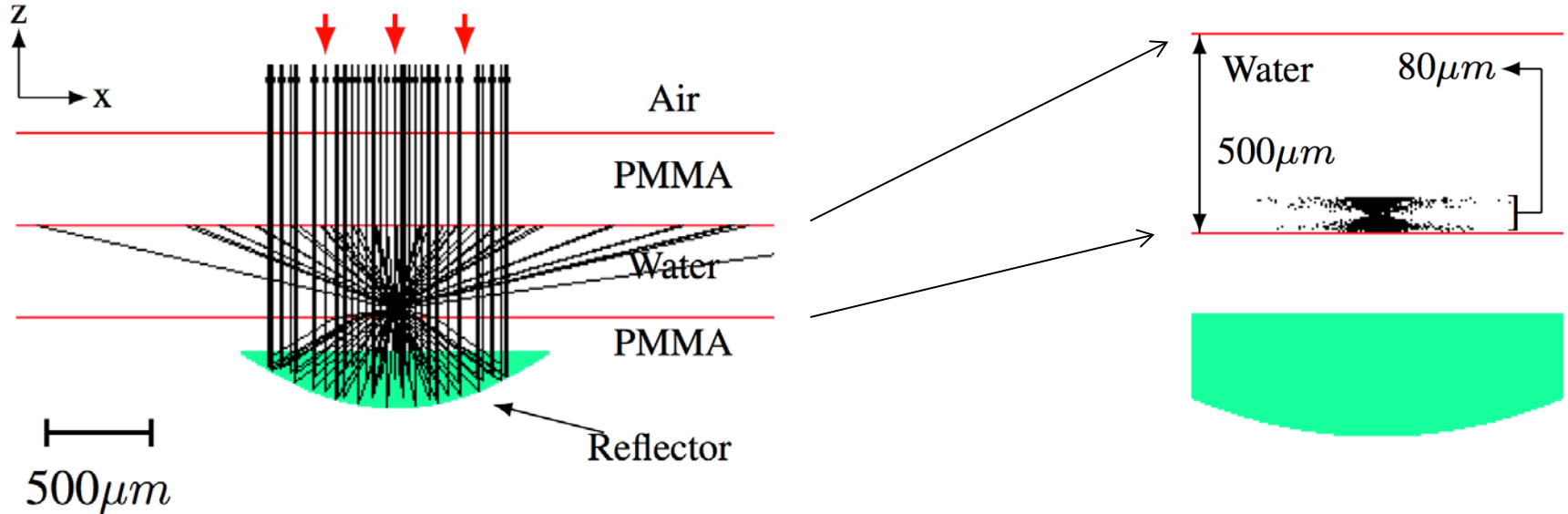
- Maximize the throughput by using free-form reflector lens:



- Non-parabolic reflector focuses a collimated incident light beam to the focal point \Rightarrow good performance
- geometry design based on the **principle of a parabolic reflector** and **Fermat's principle**, taking the refraction before focus into account:

$$n_1|Q_i S_i| + n_2|S_i P_i| + n_2|P_i R_i| + n_1|R_i F_i| = \text{constant}$$
- geometry is determined numerically \Rightarrow result: free-form reflector shape

- Maximize the throughput by using free-form reflector lens:



Simulation:

- non-sequential ray-tracing in Breault ASAP
- generation of Raman scattering in Matlab

Source:

- collimated Gaussian beam
- $\lambda = 785\text{nm}$
- beam waist is half of reflector diameter

- Maximize the throughput by using free-form reflector lens:



UDT used to prototype the free-form lens directly in PMMA:

-radius diamond tool: 221.3 μm

PMMA reflector:

-average ROC: 1.284 mm

-diameter: 1.6 mm

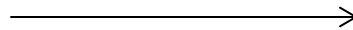
-height: 300 μm



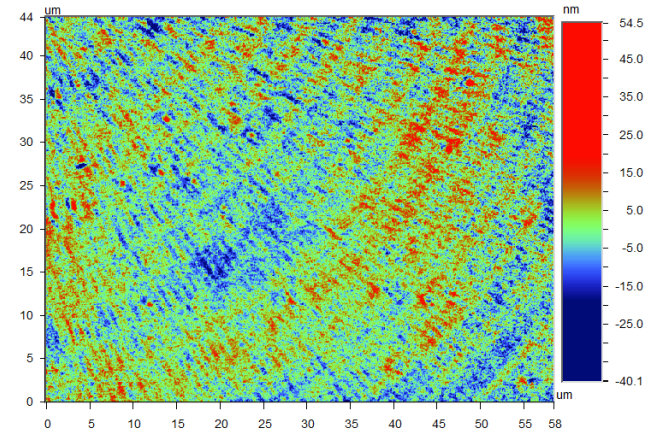
200nm gold coating
(Chemical Vapor Deposition)



Characterization
(non-contact optical surface profiler)



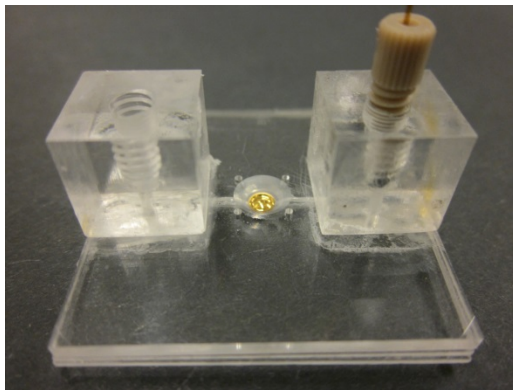
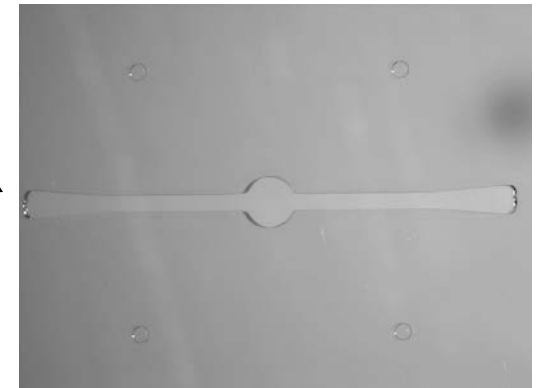
RMS roughness = 9 nm (std = 1.24 nm)
22 evaluation areas (45 μm x 60 μm)



- Assembly of the LoC:

Lab-on-chip consists of 3 PMMA layers:

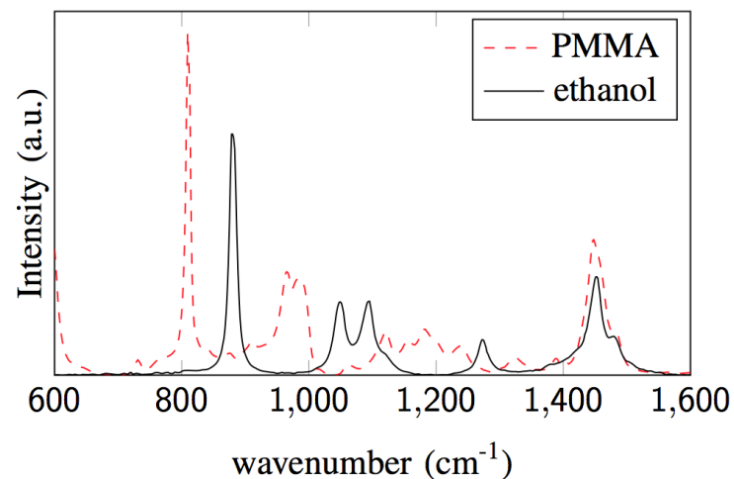
- top layer (in- and outlet holes): milling
- middle layer (fluidic channel): milling
- bottom layer (reflector): diamond tooling



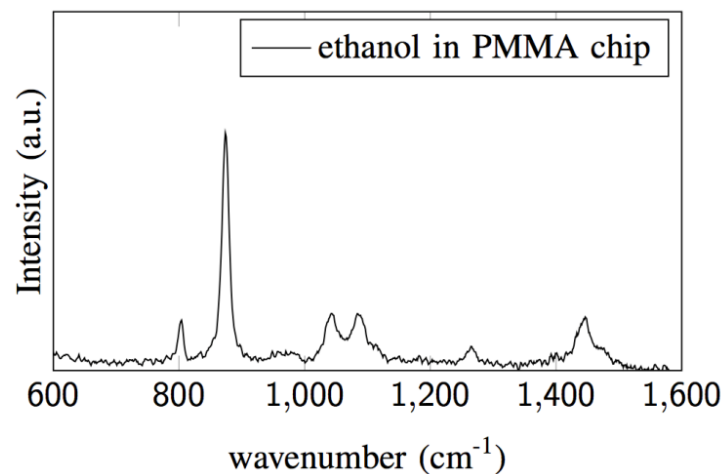
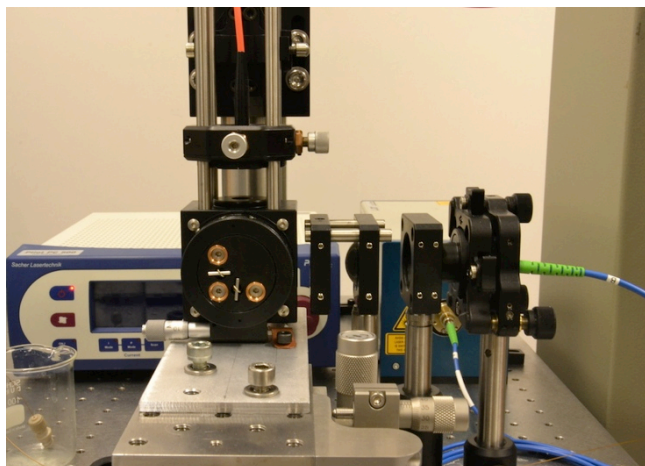
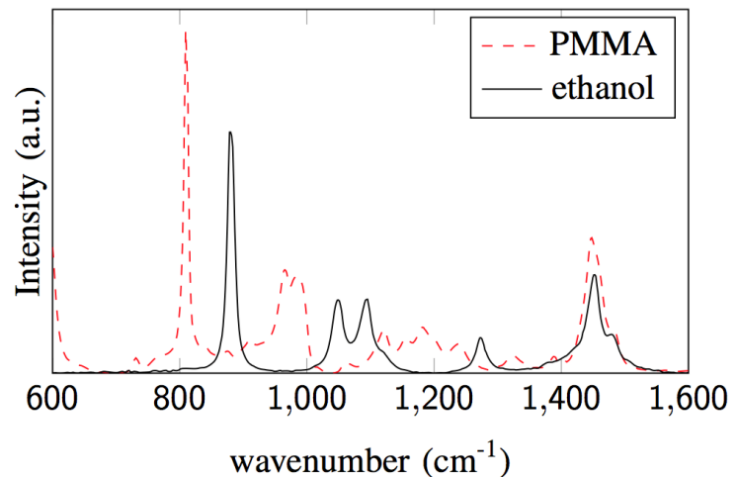
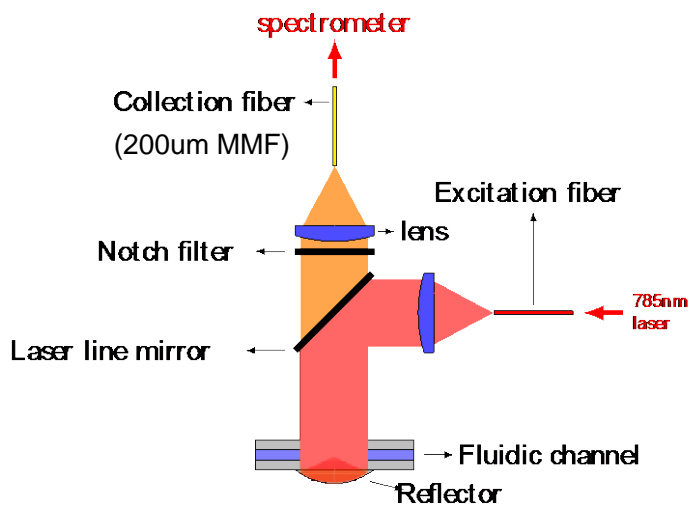
- Proof-on-concept demonstration: reference measurement



Raman spectrometer



- Proof-on-concept demonstration: background suppression

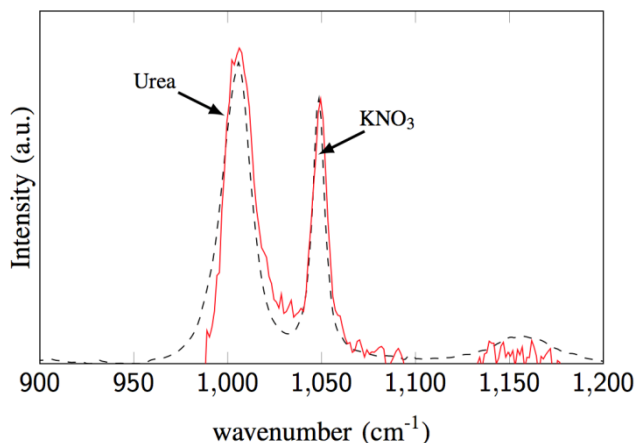


PMMA background suppression: factor 7

- Proof-on-concept demonstration: Raman measurements on urea solutions

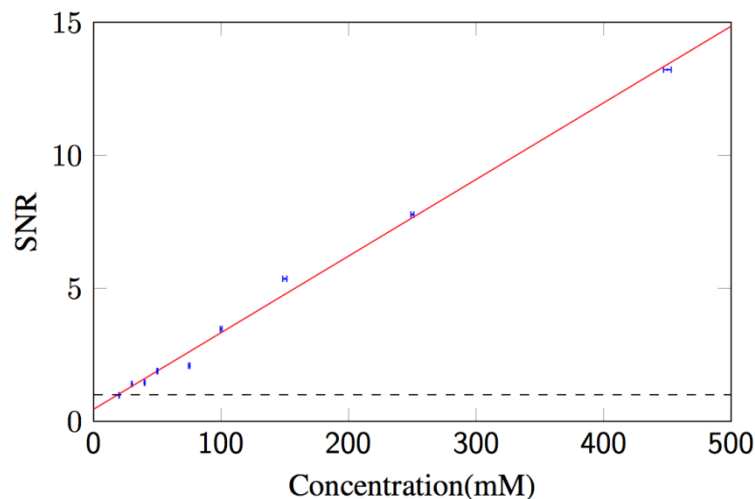
Calibration of the system:

- Raman measurements on urea solutions with known concentrations
- making use of an internal standard (KNO_3) for normalization



Mixture 450mM urea and 100mM KNO_3

- reflector based Raman chip
- - - commercial Raman spectrometer



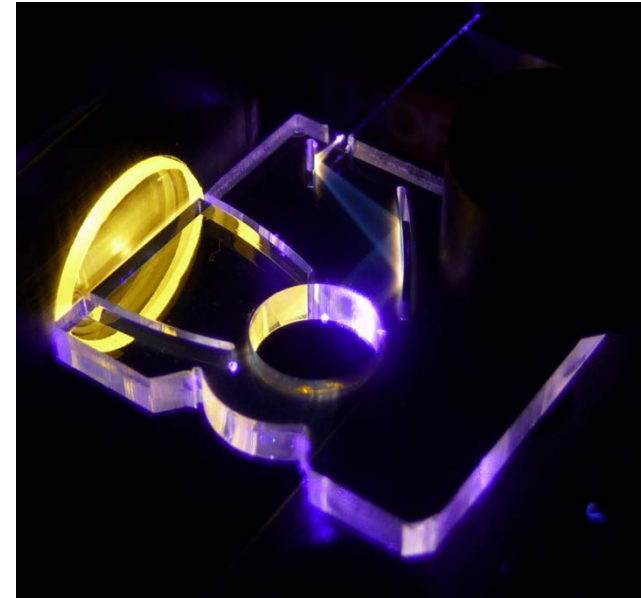
Calibration curve for urea:

$$\text{SNR} = \text{mean}(\text{peak area}) / \text{std}(\text{peak area}) \text{ over 10 measurements}$$

Noise Equivalent Concentration = 20mM
(acquisition time = 15s, power 190mW)

Wafer-scale production of photonics-enhanced labs-on-chips holds tremendous potential for

- Low-cost mass production
- Wafer-scale integration with electronics for source/detector
- True disposability
- Biocompatibility / biodegradability
- Ubiquitous deployment



Visit us at www.b-phot.org for more information